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Customer No. 20,995

## Docket No.: SHIGA7.032APC

## INFORMATION DISCLOSURE STATEMENT

Applicant

Hojo et al.

Int. App. PCT/JP2004/005804

No

Int. Filing

Date

For

**POSITIVE PHOTORESIST** 

COMPOSITION AND METHOD FOR

FORMING RESIST PATTERN

Examiner

Unknown

Art Unit

Unknown

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

Dear Sir:

Enclosed for filing in the above-identified application is a PTO/SB/08 Equivalent listing 14 references to be considered by the Examiner. Also enclosed are 10 foreign patent references and/or non-patent literature as listed on the Information Disclosure Statement. The relevance of all foreign-language references is that they were cited in the International Search Report during the International Phase of the present application.

This Information Disclosure Statement is being filed within three months of the filing date, and no fee is required. However, the Commissioner is hereby authorized to charge any fees which may be required to Account No. 11-1410.

Respectfully submitted,

KNOBBE, MARTENS, OLSON & BEAR, LLP

Dated: 26 Oct. 2005

By: ( Daniel E. Altman

Registration No. 34,115

Attorney of Record

Customer No. 20,995

(949) 760-0404

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PTO/SB/08 Equivalent

	Application No.	Unknown 10/554380
INFORMATION DISCLOSURE	Filing Date	Herewith
STATEMENT BY APPLICANT	First Named Inventor	Hojo, Takuma
	Art Unit	Unknown
(Multiple sheets used when necessary)	Examiner	Unknown
SHEET 1 OF 1	Attorney Docket No.	SHIGA7.032APC

	U.S. PATENT DOCUMENTS					
Examiner Initials	Cite No.	Document Number Number - Kind Code (if known) Example: 1,234,567 B1	Publication Date MM-DD-YYYY	Name of Patentee or Applicant	Pages, Columns, Lines Where Relevant Passages or Relevant Figures Appear	
	1	US 2003/0113661 A1	06-19-2003	Uetani et al.		
	2	6,627,381 B1	09-30-2003	Uetani et al.		
	3	US 2002/0068238 A1	06-06-2002	Hada et al.		
	4	6,033,828	03-07-2000	Shimada et al.		

FOREIGN PATENT DOCUMENTS						
Examiner Initials	Cite No.	Foreign Patent Document  Country Code-Number-Kind Code  Example: JP 1234567 A1	Publication Date MM-DD-YYYY	Name of Patentee or Applicant	Pages, Columns, Lines Where Relevant Passages or Relevant Figures Appear	T <sup>1</sup>
	5	WO 01/73512 A1	04-10-2001	Sumitomo Chem. Co.		Abstract
	6	JP 2002-6501	01-09-2002			
	7	UK 2,356,258 A	05-17-2001	Sumitomo Chem. Co.		
	8	WO 00/46640	08-10-2000	Sumitomo Chem. Co.		Abstract
	9	JP 2003-321520	11-14-2003			
	10	EP 1,357,428 A1	10-29-2003	Nippon Shokumbai Co.		Х
	11	JP 2002-241442	08-28-2002	Daicel Chem Ind. Ltd.		Abstract
	12	JP 2002-169292	06-14-2002			
	13	JP 10-268508	10-09-1998			

	NON PATENT LITERATURE DOCUMENTS			
Examiner Initials	Cite No.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T <sup>1</sup>	
	14	International Search Report from priority PCT application serial no. PCT/JP 2004/005804.		
		·		

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**Examiner Signature** 

**Date Considered** 

<sup>\*</sup>Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

T<sup>1</sup> - Place a check mark in this area when an English language Translation is attached.